

UNITED STATES PATENT AND TRADEMARK OFFICE

BEFORE THE PATENT TRIAL AND APPEAL BOARD

LAM RESEARCH CORP.,

Petitioner

v.

DANIEL L. FLAMM,

Patent Owner

U.S. Patent No. 6,017,221

Issued: Jan. 25, 2000

Named Inventor: Daniel L. Flamm

Title: PROCESS DEPENDING ON PLASMA
DISCHARGES SUSTAINED BY INDUCTIVE COUPLING

POWER OF ATTORNEY

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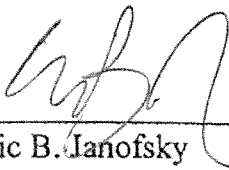
Pursuant to 37 C.F.R. 42.10(b), Petitioner Lam Research Corp. hereby appoints the practitioners associated with Irell & Manella's Customer No. 29000 as its attorneys to transact all business in the United States Patent and Trademark Office for the *Inter Partes* Review of U.S. Patent No. 6,017,221. Lam Research Corp. further appoints Michael R. Fleming as the lead counsel and Samuel K. Lu as back up counsel, as well as Morgan Chu (*pro hac vice* to be requested upon authorization) and Talin Gordnia (*pro hac vice* to be requested upon authorization).

| LEAD COUNSEL | BACKUP COUNSEL |
|--|---|
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The individual signing below has the authority to execute this document on
behalf of Lam Research Corp.

Dated: August 12, 2015

By: 
Eric B. Janofsky
Vice President, Intellectual Property
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